

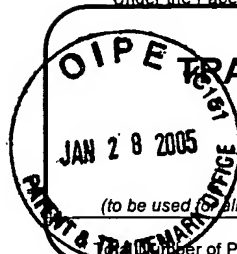
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Number of Pages in This Submission

9+

Application Number	10/816,179
Filing Date	March 31, 2004
First Named Inventor	Chung J. Lee
Art Unit	1763
Examiner Name	
Attorney Docket Number	DSI 302

**ENCLOSURES** (Check all that apply)

<input type="checkbox"/> Fee Transmittal Form	<input type="checkbox"/> Drawing(s)	<input type="checkbox"/> After Allowance Communication to TC
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<input type="checkbox"/> Express Abandonment Request	<input type="checkbox"/> Terminal Disclaimer	1. PTO-1449 Forms (6)
<input checked="" type="checkbox"/> Information Disclosure Statement (Supplemental)	<input type="checkbox"/> Request for Refund	2. Foreign References (12)
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**SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT**

Firm Name	Alleman Hall McCoy Russell & Tuttle LLP		
Signature	<i>M. Matthews Hall</i>		
Printed name	M. Matthews Hall		
Date	January 26, 2005	Reg. No.	43,653

**CERTIFICATE OF TRANSMISSION/MAILING**

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This collection of information is required by 37 CFR 1.5. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.11 and 1.14. This collection is estimated to 2 hours to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Date: January 26, 2005

CHUNG J. LEE, ATUL KUMAR,  
CHIEH CHEN and YURI PIKOVSKY

Serial No. : 10/816,179

Group Art Unit 1763

Filed : March 31, 2004

For : SYSTEM FOR FORMING COMPOSITE  
POLYMER DIELECTRIC FILM

Mail Stop AMENDMENT  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Sir:

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**  
**UNDER 37 C.F.R. §§ 1.56, 1.97, and 1.98**

Applicants are submitting this Supplemental Information Disclosure Statement pursuant to 37 C.F.R. §§ 1.56, 1.97, and 1.98 to disclose to the U.S. Patent and Trademark Office the patents, publications, applications, and/or other references listed on the enclosed, completed PTO-1449 form(s). The filing of this Supplemental Information Disclosure Statement should not be construed as a representation that a search has been made or as an admission that the listed references are prior art for this application. Applicants respectfully request that the listed references be expressly considered during prosecution of the application, and that the references be made of record therein and appear among the "references cited" on any patents issuing therefrom.

## CONTENT OF DISCLOSURE

This Supplemental Information Disclosure Statement includes (1) six pages of PTO-1449 forms, and (2) a legible copy of each foreign and non-patent reference, if any, listed on the form(s). However, because this application was filed on or after July 1, 2003, no copies of U.S. patents or published U.S. patent applications are included.

## TIMING OF DISCLOSURE / FEE INFORMATION

This Supplemental Information Disclosure Statement is being filed, to the best of the undersigned's knowledge, either (1) before the mailing of a first Office action on the merits, or (2) before the mailing of a first Office action after the filing of a request for continued examination under 37 C.F.R. § 1.114. Therefore, in accordance with 37 C.F.R. § 1.97(b), no fee or statement under 37 C.F.R. § 1.97(e) is required.

Please contact the undersigned with any questions or comments regarding this Supplemental Information Disclosure Statement.

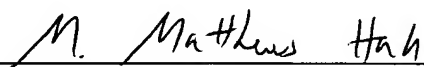
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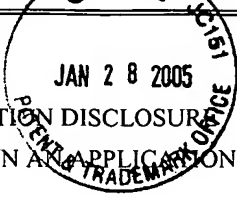
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\_\_\_\_\_  
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Respectfully submitted,

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Attorney for Assignee

FORM PTO-1449		DOCKET NUMBER DSI 302		APPLICATION NUMBER 10/815,994		
		APPLICANTS Chung J. Lee et al.				
		FILING DATE March 31, 2004		GROUP ART UNIT 2827		
U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.
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	EP 0 349 032 A2	01/03/1990	EPO			
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	WO 97/15951	05/01/1997	WIPO			
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	6,703,462	03/09/2004	Lee			
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	Plano et al., <i>The Effect of Deposition Conditions on the Properties of Vapor-Deposited Parylene Af-4 Films</i> , <u>Material Research Society Symposium Proceedings</u> , Vol. 476, pp. 213-218, 1997.					
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	2003-0198578	10/23/2003	Lee			
	2003-0196680	10/23/2003	Lee			
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OTHER DOCUMENTS						
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EXAMINER			DATE CONSIDERED			